Formation of silicon nitride layers by nitrogen implantation into Si/CoSi2 systems

Almonacid L, Schippel S, Witzmann A.

Nuclear Instruments and Methods in Physics Research, Section B: Beam Interactions with Materials and Atoms
1992; 65(1-4):84-87

ARTICLE IDENTIFIERS
DOI: 10.1016/0168-583X(92)95017-L
PMID: unavailable
PMCID: not available

JOURNAL IDENTIFIERS
LCCN: not available
pISSN: 0168-583X
eISSN: not available
OCLC ID: not available
CONS ID: not available
US National Library of Medicine ID: not available